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* English language abstract provided for the Examiner's convenience

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MAY 12 2006

**INFORMATION DISCLOSURE CITATION
IN AN APPLICATION FOR TRADEMARK**

(Use several sheets if necessary)

Attorney Docket No.:
8051-1036

Application No.:

Applicant:
Shinichi SUMIDA et al.

Filing Date:

January 5, 2006

Group Art Unit:

U.S. PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

By

KODAMA et al., "Synthesis of Novel Fluoropolymer for 157 nm Photoresists by Cyclopolymerization", Proceedings of SPIE, Vol. 4690, 2002, pp. 76-83.

EXAMINER:

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.

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